

BOX AF
REPLY UNDER 37 C.F.R. § 1.116
EXPEDITED PROCEDURE
EXAMINING GROUP 1752

PATENT
2224-0163P

IN THE U.S. PATENT AND TRADEMARK OFFICE

Applicant: NAKANO, T. Conf.: 5816
Appl. No.: 09/463,059 Group: 1752
Filed: January 19, 2000 Examiner: Y. CLARKE
For: ACID-SENSITIVE COMPOUND AND RESIN
COMPOSITION FOR PHOTORESIST

LARGE ENTITY TRANSMITTAL FORM
FOR REPLY AFTER FINAL UNDER 37 C.F.R. § 1.116

BOX AF

Assistant Commissioner for Patents
Washington, DC 20231

February 11, 2002

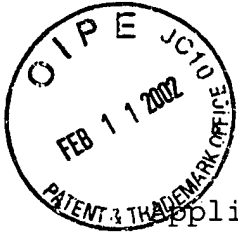
Sir:

Transmitted herewith is an amendment in the above-identified application.

- ☐ The enclosed document is being transmitted via the Certificate of Mailing provisions of 37 C.F.R. § 1.8.
- ☐ The enclosed document is being transmitted via facsimile.

The fee has been calculated as shown below:

	CLAIMS REMAINING AFTER AMENDMENT			HIGHEST NUMBER PREVIOUSLY PAID FOR			PRESENT EXTRA	RATE	ADDITIONAL FEE
TOTAL	14	-		20	=		0	\$ 18	\$0.00
INDEPENDENT	1	-		3	=		0	\$ 84	\$0.00
<input type="checkbox"/> FIRST PRESENTATION OF A MULTIPLE DEPENDENT CLAIM								\$280	\$0.00
								TOTAL	\$0.00



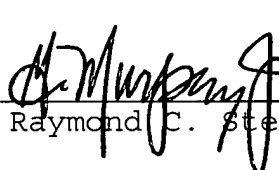
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- ☐ Petition for () month(s) extension of time pursuant to 37 C.F.R. §§ 1.17 and 1.136(a). \$0.00 for the extension of time.
- ☒ No fee is required.
- ☐ Check(s) in the amount of \$0.00 is(are) enclosed.
- ☐ Please charge Deposit Account No. 02-2448 in the amount of \$0.00. This form is submitted in triplicate.


If necessary, the Commissioner is hereby authorized in this, concurrent, and future replies, to charge payment or credit any overpayment to Deposit Account No. 02-2448 for any additional fees required under 37 C.F.R. §§1.16 or 1.17; particularly, extension of time fees.

Respectfully submitted,

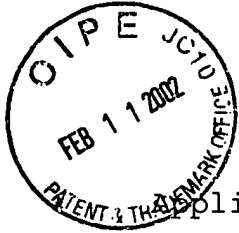
BIRCH, STEWART, KOLASCH & BIRCH, LLP

By  #28977
Raymond C. Stewart, #21,066

P.O. Box 747
Falls Church, VA 22040-0747
(703) 205-8000


RCS-JW/end
2224-0163P

BOX AF
REPLY UNDER
37 C.F.R. § 1.116
EXPEDITED PROCEDURE



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2224-0163P

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COMPOSITION FOR PHOTORESIST

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REPLY AFTER FINAL UNDER 37 C.F.R. § 1.116

BOX AF
Assistant Commissioner for Patents
Washington, DC 20231

February 11, 2002

Sir:

In reply to the Final Office Action dated November 9, 2001,
the following amendments and remarks are respectfully submitted in
connection with the above-identified application.

AMENDMENTS

IN THE CLAIMS:

Please amend the claims as follows:

1. (Twice Amended) An acid responsive compound represented

by the following formula (1)

Handwritten signature: [Signature]